❖ List of Symbols

ν	laser frequency	E_1	excited state energy level
λ	laser wavelength	Ea	activation energy
φ	incident angle	E _c	energy of the conduction band edge
τ	lifetime	E_{F}	Fermi level
Ω	ohm	E _{Fc, Fv}	quasi Fermi levels
σ	conductivity	E _g	band-gap energy
ρ	density		energy difference of cladding
λ_0	center wavelength of the laser	$E_{g,cl}$	layers
θ_0	angles of incidence in the	$E_{\mathbf{v}}$	energy of the valance band edge
	incident medium	eV	electron volt
η_d	differential efficiency	g	optical gain
ΔE	energy separation between quasi fermi levels	gm	gram
Гg	modal gain	g_{th}	threshold gain
	absorption coefficient	h	Plank's constant
α_{i}	•	hν	energy of photon
η _i	internal efficiency	hr	hour
ΔI	change in operating current	I_0	initial intensity
ΔΡ	change in output power	I_{op}	operating current
Γ- point	center of the brillouin zone	I_{rt}	intensity after a round trip
$\theta_{\rm s}$	angles of incidence in the substrate	I_{th}	threshold current
		J_{th}	threshold current density
η_{slope}		k_b	Boltzmann's constant
or an/ar	slope efficiency	k	momentum
dP/dI		K	kelvin
μ	mobility	kT	kinetic energy of an atom
μm	micrometer	L	laser cavity length
μ_{n}	mobility of electron	M	characteristic matrix
$\mu_{\rm p}$	mobility of hole	m	meter
A	group III constituent species	N_0	number of atoms in ground state
C	velocity of light in vacuum	n.'	effective refractive indices of
D	group V constituent species	n_0'	the incident medium
d	thickness	N_1	number of atoms in excited state
E_0	ground state energy level		

n_a	refractive index of the air	$R_{1,2}$	facet mirror reflectivity
n_{cl}	refractive index of cladding	r_{g}	growth rate
	layer	R_n	lower order organic radical
n_{eff}	effective refractive index	R_{nr}	non-radiative recombination rate
$n_{\rm f}$	refractive index of core layer	R_{rr}	radiative recombination rate
n_{H}	high refractive index	R_s	dynamic series resistance
$n_{L} \\$	low refractive index	R_{SP}	spontaneous emission rate
nm	nanometer	R_{th}	thermal resistance
n_s	refractive index of semiconductor	S	second
$n_s{'}$	effective refractive indices of the substrate	T	temperature
		t	time
P	reactor pressure	T_0	characteristic temperature
P_0	initial power	T_j	junction temperature
P_{COMD}	power level at COMD	V	gas velocity
P_{max}	maximum power	V_0	turn-on voltage
P_{out}	optical output power	V_b	bias voltage
q	electronic charge	V_{f}	forward voltage
R	reflectivity at normal incident	W	watt
r	molecular diameter		

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